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708

U.S. UTILITY Patent Application

PATENT NUMBER and  
ISSUE DATE

APPL NUM 10004714	FILING DATE 12/05/2001	CLASS 257	SUBCLASS 306	GAU 2014	EXAMINER PERALTA
<b>**APPLICANTS:</b> Meikle Scott; Dean Trung;					
<b>**CONTINUING DATA VERIFIED:</b> THIS APPLICATION IS A DIV OF 09/537,238 03/28/2000 WHICH IS A DIV OF 08/977,800 11/25/1997 - <i>Division</i> WHICH IS A CON OF 08/667,907 06/12/1996 PAT 5,691,235 WHICH IS A CON OF 08/348,646 11/30/1994 ABN					
<b>** FOREIGN APPLICATIONS VERIFIED:</b>					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/> RESCIND <input type="checkbox"/>					
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no			ATTORNEY DOCKET NO 303.444US5		
Verified and Acknowledged Examiner's initials					
TITLE : Method of depositing tungsten nitride using a source gas comprising silicon					
<small>U.S. DEPT. OF COMM./PAT. &amp; TM.-PTO-4351 (Rev. 12-01)</small>					

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
<b>ISSUE FEE</b>		Assistant Examiner	
Amount Due	Date Paid	Primary Examiner	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>PREPARED FOR ISSUE</b>	
		Application Examiner	
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